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Image

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN RE APPLICATION OF:

Atsushi SHIOTA, et al.

: GROUP: 1712

SERIAL NUMBER: 09/770,289

:EXAMINER: FEELY, M.

FILED: January 29, 2001

FOR: PROCESS FOR PRODUCING SILICA-BASED FILM,
SILICA-BASED FILM, INSULATING FILM, AND
SEMICONDUCTOR DEVICE

STATUS REQUEST

Honorable Commissioner of Patents & Trademarks
Alexandria, Virginia 22313

SIR:

The Patent Office is respectfully requested to inform the undersigned of the approximate date on which further action will be taken on this Application. A Petition for Retroactive License for Foreign Filing Under 35 U.S.C. 184 (2 pp.) Declaration in Support of Petition for Retroactive License for Foreign Filing Under 35 U.S.C. 184 (3 PP., executed) Copy of Official Filing Receipt dated May 2, 2001 and a Request for Extension of Time Under 37 C.F.R. §1.36 (one month) were filed September 16, 2003.



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Respectfully submitted,

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